Supporting information

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Figure S1. Raman spectroscopy, showing typical Raman spectral peaks of FL (a) WS_2 (b) WSe_2 , at a laser excitation wavelength of 514 nm.



Figure S2. Atomic force microscopy, showing height profiles of TMDs along with their inset topographical images. (a) and (b) Height profile of WSe_2 and WS_2 for device1 and device2 respectively. (c) Height profile of h-BN used as a supporting base for device2.



Figure S3. Hysteresis behavior $(I_{ds}-V_{bg})$ curve at $V_{ds}=1$ V on h-BN substrate for (a) WSe₂ (b) WS₂, whereas each inset figure show that on SiO₂ substrate.



Figure S4. Back-gate depndent diode I_{ds} - V_{ds} curves plotted in the semi-log scale for (a) device1 and (b) device2.